



- (51) **International Patent Classification:**  
*G01F 1/34* (2006.01) *G01F 1/20* (2006.01)
- (21) **International Application Number:**  
PCT/US2015/054698
- (22) **International Filing Date:**  
8 October 2015 (08.10.2015)
- (25) **Filing Language:** English
- (26) **Publication Language:** English
- (30) **Priority Data:**  
62/061,538 8 October 2014 (08.10.2014) US
- (71) **Applicant:** AIR PRODUCTS AND CHEMICALS, INC.  
[US/US]; 7201 Hamilton Boulevard, Allentown, PA 18195 (US).
- (72) **Inventors:** BAYER, Benjamin Patrick; 7201 Hamilton Boulevard, Allentown, PA 18195 (US). CHAN, Laura Suk Chong; 7201 Hamilton Boulevard, Allentown, PA 18195 (US). EREIFEJ, Fady Khalil; 7201 Hamilton Boulevard, Allentown, PA 18195 (US). ROYBAL, Daniel Valentin; 7201 Hamilton Boulevard, Allentown, PA 18195 (US).
- (74) **Agent:** NEAGLE, Damon A.; 5050 W. Tilghman St., Suite 435, Allentown, PA 18104 (US).

(81) **Designated States** (unless otherwise indicated, for every kind of national protection available): AE, AG, AL, AM, AO, AT, AU, AZ, BA, BB, BG, BH, BN, BR, BW, BY, BZ, CA, CH, CL, CN, CO, CR, CU, CZ, DE, DK, DM, DO, DZ, EC, EE, EG, ES, FI, GB, GD, GE, GH, GM, GT, HN, HR, HU, ID, IL, IN, IR, IS, JP, KE, KG, KN, KP, KR, KZ, LA, LC, LK, LR, LS, LU, LY, MA, MD, ME, MG, MK, MN, MW, MX, MY, MZ, NA, NG, NI, NO, NZ, OM, PA, PE, PG, PH, PL, PT, QA, RO, RS, RU, RW, SA, SC, SD, SE, SG, SK, SL, SM, ST, SV, SY, TH, TJ, TM, TN, TR, TT, TZ, UA, UG, US, UZ, VC, VN, ZA, ZM, ZW.

(84) **Designated States** (unless otherwise indicated, for every kind of regional protection available): ARIPO (BW, GH, GM, KE, LR, LS, MW, MZ, NA, RW, SD, SL, ST, SZ, TZ, UG, ZM, ZW), Eurasian (AM, AZ, BY, KG, KZ, RU, TJ, TM), European (AL, AT, BE, BG, CH, CY, CZ, DE, DK, EE, ES, FI, FR, GB, GR, HR, HU, IE, IS, IT, LT, LU, LV, MC, MK, MT, NL, NO, PL, PT, RO, RS, SE, SI, SK, SM, TR), OAPI (BF, BJ, CF, CG, CI, CM, GA, GN, GQ, GW, KM, ML, MR, NE, SN, TD, TG).

**Published:**

— with international search report (Art. 21(3))

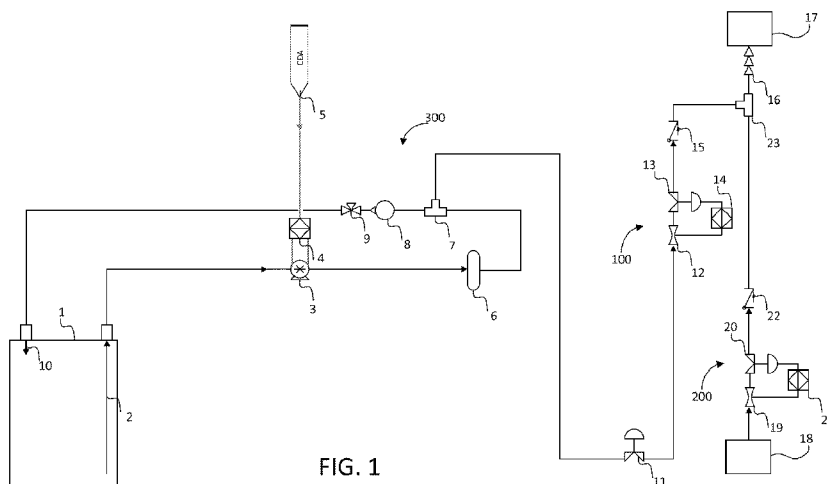
(54) **Title:** LOW PRESSURE FLUCTUATION FLOW CONTROL APPARATUS AND METHOD

FIG. 1

(57) **Abstract:** This invention provides apparatuses and methods to supply a steady volume of liquid with low pressure fluctuation that can be used to form a liquid blend or to supply other equipment or tools. The invention uses a flow controller that controls the flow rate for liquid that is fed to a liquid supply pipe from a recirculation loop that is connected thereto, the recirculation loop has a dip tube for insertion into a liquid supply container, pump, and liquid backpressure control device.

## TITLE OF THE INVENTION:

Low Pressure Fluctuation Flow Control Apparatus and Method

## BACKGROUND OF THE INVENTION

5   **[0001]** This application claims the benefit of priority under 35 U.S.C. § 119(e) to earlier filed U.S. patent application Serial No. 62/061,538, filed on 8 October 2014, having the title "Slurry Supply Apparatus and Method", which is entirely incorporated herein by reference.

10   **[0002]** There are several blending techniques commonly employed to blend ingredients for use in a semiconductor fabrication facility. Ingredients may include one or more of the following: liquids such as water, CMP slurry (abrasives and water or other diluent), hydrogen peroxide, acids, bases and other chemicals. The common blending methods include scale blending, which uses a scale having load cells to weigh ingredients in a mix tank. Another common method is beaker blending, which uses volumetric vessels to measure ingredients, that are then transferred from the volumetric vessels to a mix tank. A final common method is flow controller blending, which uses flow controllers to measure ingredients.

15   **[0003]** There are many types of flow controllers on the market. The term "flow controller" as it is employed in this document means the type that controls the control valve based on feedback from the flow meter, creating a closed-loop control system, with a response time to setpoint changes of less than 3 seconds.

20   **[0004]** The advantage of scale blending and beaker blending is they can employ pumps to transfer ingredients directly from slurry supply containers to the mix tank (to be weighed) or to the volumetric vessels. In contrast, reliable flow controller blending has, prior to this invention, required two pumps and a tank to accomplish a similar task. One disadvantage of scale and beaker techniques is the requirement for a mix tank. Another disadvantage is the delay that occurs in the process during mixing in the mix tank.

25   **[0005]** The advantage of flow controller blending is immediate availability of the blend. Scale and beaker blending requires a delay for mixing in a mix tank. Flow controller blending does not require a delay or a mix tank. An advantage of scale or beaker blending techniques is they are capable of blending accurately even when ingredient supply pumps cause significant pressure variation. In contrast, flow controller blending is

sensitive to pressure variation. High supply pressure variation can cause the flow controller to over-adjust. Over-adjustment is defined as making rapid adjustments in response to short-duration, rapidly changing signals, which results in amplification of process variation rather than reduction.

- 5   **[0006]** Pressure variation is typically defined as the coefficient of variation, CV of pressure (PSIG). CV is calculated from 600 data points, 1 data point collected per second, per the equation below:

$CV(\pm\%) = \frac{\sigma}{\mu}$  Where  $\sigma$  is defined as the standard deviation ( $1\sigma$ ) of liquid pressure (PSIG) and  $\mu$  is defined as the mean of liquid pressure (PSIG).

10

- [0007]** One solution to the flow controller sensitivity problem is to use an apparatus that supplies the flow controllers via a low pressure variation pump, such as a bearingless magnetically levitated ("maglev") pump. Maglev pumps must be gravity primed. Gravity priming in turn requires a slurry supply container having a cone-bottom tank and  
15 physically locating the pump below the level of the cone's bottom. This apparatus permits low pressure variation delivery to the flow controller. Bearingless magnetically levitated centrifugal pumps have no suction lift capability. So to transfer ingredients into the tank requires another pump with suction lift capability. The end result is that flow controller blending is more expensive than scale or beaker blending because of the  
20 additional tank and maglev pump required to reduce pressure variation.

**[0008]** The apparatus of the present invention does not require the maglev pump or gravity-prime tank.

- [0009]** Related references include: US6168048, US5573385, US6364640, US6095194, US7108241, US5983926, US5983926, US6889706, US8155896,  
25 US7885773, US7447600, US7650903, and US7292945, all of which are incorporated herein by reference.

- [0010]** There is still a need for an apparatus and method that provides consistent flow from a pump to a flow controller that is compact, of reduced complexity, eliminates costly parts, like pressure vessels, and uses reliable equipment and methods to provide low  
30 pressure fluctuation in a liquid stream that can be used for a variety of fluids, including slurries.

## BRIEF SUMMARY OF THE INVENTION

**[0011]** The invention provides an improved apparatus and method to supply a (volumetric liquid) flow controller with low pressure fluctuation. The invention comprises a pump and a flow controller. The pump has closed-loop flow rate control. The pump flow rate control helps eliminate pressure fluctuation. The pump may be a low pressure fluctuation pump and/or a pump in series with a pressure regulator. The pump flow capacity may be in a certain ratio with the pressure regulator for pressure fluctuation to be reduced effectively.

**[0012]** The apparatus of the invention is one aspect of the invention. Another aspect is the process of the invention which permits low pressure variation. By carefully adjusting the process, the apparatus provides low pressure variation. Conversely, without the apparatus adjustable characteristics, the process would not provide low pressure variation. To summarize, the invention is an adjustable apparatus and process of operating the apparatus to achieve low pressure variation and thereby low variation in the flow of the raw slurry to be blended or other liquids that may be blended or consumed downstream of the apparatus of this invention.

**[0013]** The term “flow controller” refers to a device having a flow meter, a control valve, and a controller and is used to also include a volumetric liquid flow controller having a flow meter, and controller and a regulator-and-control-valve-in-one. The term regulator-and-control-valve-in-one refers to the unique property used in some embodiments of the invention that provides a flow controller, containing a regulator, a flow meter and a controller, such that the regulator function which provides pressure fluctuation suppression and the control valve function which provides flow rate adjustment are both implemented at the same time by the same device. The regulator-and-control-valve-in-one is further improved in some embodiments of the invention by placing the regulator-and-control-valve-in-one in an upstream position relative to a flow meter so the flow meter can measure the pressure suppression effect of the regulator-and-control-valve-in-one. The regulator-and-control-valve-in-one is further improved in some embodiments of the invention by a controller that permits the user to define operating pressure ranges whereby the regulator-and-control-valve-in-one is optimally effective suppressing pressure fluctuation and controlling flow rate. The term “controlled regulator” may be used interchangeably with the term “regulator-and-control-valve-in-one”. Additionally the use of the term “regulator” includes the controlled regulator and a regulator without a controller. The invention operates a regulator in a certain pilot pressure (for gas, air) range which provides pressure fluctuation suppression while controlling flow effectively. This innovation eliminates the need for separate regulator and control valve.

**[0014]** The invention provides one or more of the following advantages. The invention does not contain a pressure vessel, making it suitable for settling CMP slurries. The invention does not employ a pulse dampener, which have reliability drawbacks. In some embodiments, the low pressure fluctuation pump may not operate, as in the prior art with one chamber working and one chamber pulse suppressing, thereby increasing the pump reliability. Instead, the pump, useful in this invention, may have two working diaphragms. The pressure regulator may have two diaphragms and be free of a travel stop. In some embodiments, the pressure regulator has first and second, often upper and lower diaphragms, where the first diaphragm (typically the lower diaphragm) senses the inlet pressure. This invention may be free of wave-dissipating projections in the wall leading into the regulator. In some embodiments, those projections would promote agglomeration, for example in a CMP liquid. As stated above the regulator in the present invention may eliminate the need for a separate control valve. Additionally, therefore, the controller in the present invention can feedback to the regulator and not the control valve.

**[0015]** In one embodiment of the invention, the pressure regulator of the invention is a standard, proven design with two diaphragms connected by a shaft having a closure member, the shaft running through the valve orifice. The inlet pressure is sensed by the lower diaphragm in contact with the inlet fluid. There is no travel stop restricting pulsation dampening effectiveness of the regulator; it is travel stop free. There are no wave-dissipating projections which promote CMP liquid agglomeration. The control valve of the invention is the same pressure regulator, rather than a separate device. This is space efficient and cost effective.

**[0016]** The regulators comprising two diaphragms may be spring-loaded (direct operated), pneumatic (dome-loaded) or weight-loaded, linear-actuated, motor-loaded, or the like.

**[0017]** The invention discloses recommended operating parameters the inventors discovered. The invention discloses pilot pressure ranges for dome loaded pressure regulators which produce effective suppression of pressure fluctuation. The invention also discloses the benefit, in some embodiments, of oversizing the regulators from a flow capacity standpoint to operate the regulator at relatively low pilot pressure, which suppresses pressure fluctuation effectively, while still providing sufficient flow downstream.

**[0018]** In this invention, the flow meter may be located directly downstream of the regulator (and control valve in one). The downstream flow meter location may be

beneficial to the multi-stage pressure fluctuation suppression of the invention. The upstream regulator can serve as a control valve and as a pressure fluctuation suppression device. The flow meter downstream is thereby protected from pressure fluctuation by the regulator. The flow meter provides backpressure to the regulator, improving its effectiveness. Since the regulator may be a fail-closed, bubble-tight device, an isolation valve upstream of the flow meter is not necessary, with the invention. In this way, in addition to serving as a pressure fluctuation suppressor and a control valve, it may additionally serve as an isolation valve.

**[0019]** One type of regulator useful in this invention is a dome loaded pressure regulator. Despite being entirely mechanical, these devices are sophisticated, being capable to sense differences between inlet and outlet pressure using two diaphragms, one in contact with the inlet, the other in contact with the outlet. When the diaphragms sense a pressure change, the shaft containing the closure member, attached to both diaphragms, running through the orifice, changes position, such that the pressure fluctuation is eliminated. For example, if inlet pressure increases, the shaft presses down on the inlet diaphragm, causing the closure member to shift, opening the orifice, which relieves the pressure. Regulators operate on the energy of the process. The mechanical operating principle of regulators presents an advantageously quick, direct, consistent and reliable response to pressure fluctuations.

**[0020]** The present invention relates to a pump-driven system which supplies a volumetric liquid flow controller, where the feed-in to the volumetric liquid flow controller has as little pressure fluctuation as possible, where the flow controller is part of a closed-loop flow control system, where the pump is capable of using suction to remove liquid from a vessel, and the materials of construction of the wetted parts of the apparatus are high purity chemical resistant materials, such as PFA or PTFE.

**[0021]** The inventors have designed apparatuses for flow controlling liquids and blending components and in some embodiments blending those liquids and a process for operating the apparatuses. These apparatuses are suitable for use in semiconductor fabrication processes. The apparatus of the invention comprises a pump which uses suction to withdraw liquid from a vessel, circulate this liquid in a loop, and a flow controller that draws liquid from this loop, the flow controller being highly sensitive and accurate, notwithstanding the type of pump upstream. In another aspect of the invention, the invention provides, an apparatus of the invention comprising a flow controller that controls the flow rate for raw slurry that is fed to the raw slurry supply pipe that is blended with at least one other slurry component transported in at least one other slurry component supply pipe, each slurry component being transported in its own slurry

component supply pipe, said slurry supply pipe connected to a recirculation loop said recirculation loop comprising a dip tube for insertion into a slurry supply container, a pump, and liquid backpressure control device. The rate for raw slurry that is fed to the raw slurry supply pipe that is blended with at least one other slurry component

5 transported in at least one other slurry component supply pipe, each slurry component transported in its own slurry component supply pipe, said slurry supply pipe connected to a recirculation loop said recirculation loop comprising a dip tube for insertion into a slurry supply container, a pump, and liquid backpressure control device. The apparatus is such that a variety of characteristics can be adjusted, such as: Liquid (e.g. raw slurry)  
10 pressure in the recirculation loop, pump venturi pressure, pump diaphragm or bellow gas and vacuum flow, pump speed, pump diaphragm (or bellows) overlap, pump gas backpressure, and flow controller setpoint, which is the amount of raw slurry or other liquid desired to be blended to make a blended slurry or other liquid. Instead of using two pumps, one with suction lift capability, and one with minimal pressure variation or  
15 fluctuation (either of those terms can be used herein and can be substituted for each other), a single pump with both suction lift capability and pressure variation or fluctuation is used. By this invention the pressure variation or fluctuation caused by the pulsing or reciprocating pump (that provides suction lift) in the lines is controlled so that the pressure variation's or fluctuation's effect on the apparatus is minimized and the flow  
20 controller performance is optimal and in some embodiments, a consistently blended slurry can be achieved. Pump pressure variation or fluctuation is reduced by using the apparatus and process of the invention, which prevents flow controller over-adjustment. The invention permits direct feeding of flow controllers using a pulsing pump from slurry or other liquid supply containers. The end result of this invention is a mechanically  
25 simpler, more direct, and less expensive method of blending compared to prior art.

**[0022]** In another aspect of the invention is provided an apparatus or process of providing low pressure fluctuation flow control of liquid (and optionally subsequent blending slurry), comprising: recirculation loop for recirculating raw slurry or other liquid; slurry or other liquid material supply line in fluid communication with the recirculation  
30 loop, said slurry or other liquid material supply line having a first flow controller; the first flow controller being closed-loop control type; wherein said recirculation loop comprises a back pressure controller, pump having suction lift capacity, wherein the pump provides means for adjusting its speed and means for adjusting one or more or all of the following: chamber overlap, gas backpressure, venturi pressure and gas and vacuum flow to the  
35 one or more diaphragms or bellows; where the process of operating the apparatus comprises directing 20% or less of the slurry or other liquid in the recirculation loop to the

slurry material supply line, or in other embodiments to the flow control system. In some embodiments, the apparatus and method comprise second flow controller for a slurry component to be mixed with the raw slurry to make a slurry blend; the second flow controller being closed-loop control type; and a junction or manifold where the raw slurry and the one or more other slurry components form a blended slurry.

**[0023]** In another aspect of the invention alone or with other aspects, the process may additionally comprise operating the apparatus having a gas backpressure in the pump that is equal to or greater than the slurry or other liquid pressure in the recirculation loop when the slurry or other liquid supply pressure is measured in the recirculation loop between the pump and the junction with the slurry or other liquid material supply line.

**[0024]** In another aspect of the invention alone or with other aspects, the process of operating the apparatus comprises adjusting the gas backpressure and the venturi pressure in the pump to be equal +/- 10%.

**[0025]** In another aspect of the invention alone or with other aspects the apparatus or process of blending slurry or liquid, comprises: recirculation loop for recirculating a raw slurry or other liquid; a slurry or liquid material supply line in fluid communication with the recirculation loop, said slurry or liquid material supply line having a first flow controller; the first flow controller being closed-loop control type; second flow controller for a slurry component to be mixed with the raw slurry to make a slurry blend; the second flow controller being closed-loop control type; mixing junction or manifold where the raw slurry and the one or more other slurry components form a blended slurry; wherein said recirculation loop comprises a back pressure controller, pump having suction lift capacity, wherein the pump provides means for adjusting its speed and means for adjusting one or more or all of the following: chamber overlap, gas backpressure, venturi pressure and gas and vacuum flow to the one or more diaphragms or bellows; where the process of operating the apparatus comprises having a gas backpressure in the pump that is equal to or greater than the liquid pressure in the recirculation loop when the liquid supply pressure is measured in the recirculation loop between the pump and the junction with the liquid material line.

**[0026]** In another aspect of the invention alone or with other aspects is an apparatus and process of blending liquid, comprising: recirculation loop for recirculating a liquid; a liquid material supply line in fluid communication with the recirculation loop, said liquid material supply line having a first flow controller; the first flow controller being closed-loop control type; second flow controller for a slurry component to be mixed with the raw slurry to make a slurry blend; the second flow controller being closed-loop control type;



junction or manifold where the raw slurry and the one or more other slurry components form a blended slurry; wherein said recirculation loop comprises a back pressure controller, pump having suction lift capacity, wherein the pump provides means for adjusting its speed and means for adjusting one or more or all of the following: chamber overlap, gas backpressure, venturi pressure and gas and vacuum flow to the one or more diaphragms or bellows; wherein the process of operating the apparatus, adjusting the gas backpressure and the venturi pressure in the pump to be equal +/- 10%.

**[0027]** Any of the above described apparatuses or processes wherein the backpressure controller (or means to adjust the backpressure) in the recirculation loop is manually, electronically or pneumatically adjustable.

**[0028]** Any of the above described apparatuses or processes wherein said first flow controller for the liquid is set at 1-20 or 2-8 or 1-3 liters per minute (LPM).

**[0029]** Another aspect of the invention provides an apparatus and process of blending a liquids, where the apparatus and process comprises alone or with other aspects: recirculation loop for recirculating a first liquid; a first liquid material supply line in fluid communication with the recirculation loop, said first liquid material line having a first flow controller; the first flow controller being closed-loop control type; optional second flow controller for a second liquid component to be mixed with the first liquid to make a liquid blend; the optional second flow controller being closed-loop control type; junction or manifold where the first liquid and the one or more other liquid components form a blend liquid; wherein said recirculation loop comprises a back pressure controller, pump having suction lift capacity, wherein the pump provides means for adjusting its speed, chamber overlap, gas backpressure, venturi pressure and gas and vacuum flow to the one or more diaphragms or bellows.

**[0030]** In another aspect of the invention, the apparatus or method comprises additional component streams and additional component supply lines that are flow controlled to form the flow controlled liquid. The apparatus may comprise additional flow controllers and/or manifolds for supplying and blending those components to constitute a mixture.

**[0031]** Based on the description herein there are commercially available pumps, control valves, filter housings, check valves, control devices, instruments, liquid supply containers, backpressure controllers and mixers that may be selected so that the apparatus will function and such that the blend will be in accordance with this invention and accurate, repeatable, high purity, and not contaminated with corrosion products.

**[0032]** Corrosion resistance commonly requires the use of corrosion resistant plastics as materials of construction. Some corrosion resistant plastics include polyethylene, polypropylene, perfluoroalkoxy, polytetrafluoroethylene, and polyvinylchloride. Devices may be constructed of one or more of these materials, and other specialized corrosion resistant materials. There are many vendors of these devices available. Some vendors of suitable pumps include Yamada, Ingersoll-Rand, Nippon Pillar, Wilden, and Trebor. Some vendors of suitable valves include Entegris, SMC, Swagelok, Gemu, and Mega Flow Corporation. Some vendors of suitable control devices include Rockwell Automation, SMC, Trebor, and Entegris. Some vendors of suitable filter housings include Pall and Entegris. Some vendors of suitable check valves include Entegris, SMC and Parker. Some vendors of suitable instruments include Levitronix, Entegris, SMC, TEM-TECH and Gemu. Some vendors of liquid supply containers include Entegris and Schutz. Some vendors of back pressure controllers used to adjust the backpressure in the recirculation include Gemu, Futurestar, Entegris, and SMC. Some vendors of mixers include Edlon and SMC.

**[0033]** In one embodiment, the apparatus of the invention comprises a dip tube for inserting into a slurry or liquid supply container, that is in fluid communication with a recirculation loop. The recirculation loop further comprises in fluid communication therewith a pump, and a tee or other junction for connection to a raw slurry or liquid supply line in fluid communication with the recirculation loop. The liquid supply line either supplies optional mixing or blending equipment that may be part of the apparatus of this invention or supplies a tool or other downstream use for the liquid (that is not part of this apparatus). The slurry or liquid supply container contains a raw CMP slurry or other liquid. (The raw CMP slurry means that the raw slurry must be diluted with water or diluents and/or combined with chemical components prior to use.) The connection between the slurry or liquid supply container, pump, flow controller, and all other components (parts, not chemical components) of the recirculation loop may be (is preferably) via tubing that connects these components (parts) so that fluid can pass freely from the fluid outlet port of the upstream component to the fluid inlet port of the downstream component. (Tubing can be replaced by piping or the like.)

**[0034]** The pump is connected to a pump control device via two gas ports. The term "gas" is used to collectively refer to compressed clean dry air (CDA), nitrogen, and/or other inert gas, typically CDA. The connection between the pump, pump control device and source of gas is understood to mean tubing connects the gas to the pump and is separate from the tubing of the recirculation loop connecting the liquid supply container, pump and flow controller. High purity and chemically resistant fluid connections may be

formed by using perfluoroalkoxy (PFA) tubing and PFA fittings which fit the Flare or Female National Pipe Taper (FNPT) ports on the pump, liquid supply container, flow controllers and other components. Gas connections may be formed by using polyethylene or nylon tubing and polypropylene fittings which fit the FNPT or one-touch ports on the pump gas inlets, solenoids, and source of the gas. The pump control device attached to the gas supply turns solenoid valves on or off to separately supply two chambers of the pump. The on and off times of each solenoid is controlled by a control program loaded in the pump control device. The solenoid valves are connected to a tee, which in turn is connected to a source of gas. The pump control device is connected to a higher-level control device which operates the pump control device on demand.

**[0035]** Returning to the recirculation loop, at the tee or other junction (referred to as the tee, although it is understood the junction can be any shape connector between the recirculation loop and the liquid supply line): One side of the tee is fluidly connected directly or indirectly to the pump, a second side of the tee is connected to a line that connects ultimately to the return inlet of the liquid supply container (and is part of the recirculation loop), and the third side of the tee supplies liquid to a flow control device (flow controller), via a liquid supply line (also referred to herein as a liquid material supply line). The liquid-return side of the tee is connected to and/or in fluid communication with a variable area flow meter ("rotameter") with a needle valve, (which acts as a back pressure controller and in alternative embodiments may be a different type of back pressure controller, others are described below). The needle valve is a means to adjust backpressure in the recirculation loop. The needle valve is connected to or in fluid communication with the liquid supply container which preferably has a second, shorter diptube inserted in it for the return of liquid from the recirculation loop. The third side of the tee is connected to a flow meter (part of the flow controller). The flow meter is electronically connected to a control device or circuit, which receives setpoint signals, calculates differences between the setpoint and the actual flow, and produces an adjustment signal. The adjustment signal is sent to a control valve. A control valve is defined as a valve capable of partially or fully opening or closing in response to a pneumatic or electronic signal. The setpoint is supplied by a higher-level control device or otherwise inputted into the controller. The flow meter is connected to an electronically operated control valve. The control valve opens and closes in response to the adjustment signal provided by the control device. The flow meter and control valve are also referred to as a flow controller. The flow meter may be downstream of the control valve or the control valve may be downstream of the flow meter. Downstream of the control valve or the flow meter is a fluidly connected check valve. In some embodiments,

the check valve is connected to a second tee (it is understood it can be a junction of any shape) in the line.

**[0036]** (Note any use of “connected to” to describe any and all aspects and parts of the invention maybe replaced with the terms “fluidly connected to” and/or “in fluid

5 communication therewith”. Further, it is understood that the term connected to means that the components of the apparatus may be directly or indirectly connected to each other with one or more sections of tubing and/or other piping and/or connections and/or other parts or components connected between. Any where a connection is described “directly or indirectly connected to” or the like may be added herein.

10 **[0037]** In certain embodiments, one side of the just-mentioned second tee is connected to the outlet of the control valve or the flow meter. The second side of the second tee is connected to an optional mixing device which is connected to a reservoir or point of use for the blended liquid. The third side of the second tee is connected to a check valve, optional flow controller, and source of a second liquid component which is referred to as  
15 chemical component, e.g. water, oxidizing agent, etc. The optional mixing device or mixer mixes the two ingredients so they are fully mixed. The mixer is connected to a reservoir or point of use which stores or uses the blended liquid product.

**[0038]** In certain embodiments, the source of the second chemical component (also referred to as, ingredient) may be supplied by an external system. The second  
20 ingredient source may be connected to a second flow controller. The flow controller, if present, may comprise a flow meter and a control valve. Both the control valve and the flow meter are connected to a control device which may operate like the first flow controller, described above. Downstream of the control valve or in some embodiments, the flow meter, is a second check valve. The second check valve is connected to the  
25 second tee.

**[0039]** In alternative embodiments, two low pressure fluctuation flow control apparatuses of this invention can be used together. For example the second flow controller of the embodiment described above may be part of a flow control system (downstream of the recirculation loop) of a separate low pressure fluctuation flow control  
30 apparatus as described herein.

**[0040]** The preceding paragraphs have described embodiments of the apparatuses of the invention. In alternative embodiments, the apparatus may comprise one or more of the following alone or in any combination: additional mixing devices, flow controllers, filter housings, electronic or pneumatic control valves to adjust backpressure in the loop,  
35 a pump containing a shuttle, a pump without a controller, flow meters, pressure

transducers, pulse dampeners, shock blockers, flow switches, pneumatic valves, manual valves, and Y-strainers. These elements may be added singly, or multiply, at various points in the recirculation loop or else where in the piping or tubing of the apparatus.

**[0041]** The process of the invention may be used to overcome problems with prior art apparatuses including: difficulties removing gas from the system during startup if the apparatus comprises a filter housing in the recirculation line; difficulty of simultaneously obtaining high flow, pressure and low pressure fluctuation; and the difficulty of maintaining low pressure fluctuation when the flow controller draws off liquid from the recirculation loop. CMP liquid requires a minimum flow of 1 - 2.5 ft/s, depending on the abrasive, to prevent sedimentation of the abrasive. Typically in 1/2" tubing, approximately 3.3 LPM is required to maintain a minimum 2.5 ft/s velocity. The process of the invention seeks to provide about 3.3 LPM flow to the flow controller to prevent sedimentation. Some flow controllers require 12 PSIG or less to operate, depending on the flow controller model and brand. The process of the invention seeks to provide at least 12 PSIG liquid pressure to the flow controller to ensure flow controller operation is unimpaired. Directing flow of the liquid from the recirculation loop to the flow controller for blending provides an additional challenge. The flows and pressures in the recirculation loop must meet minimum requirements previously described. When liquid is diverted to the flow controller the pressure in the recirculation loop decreases, thereby increasing pressure fluctuation in the loop. The process of this invention provides an apparatus and a method that provides for reasonable pressures and flows to be maintained in the recirculation loop.

**[0042]** Complicating the solution to the problems described is the fact that the factors flow, pressure, and pressure fluctuation interact significantly. Backpressure and flow interact negatively. This means high backpressure causes low flow. Initially, the backpressure-flow interaction causes flow to be adequate only when backpressure was inadequate, and vice versa. A solution to this interaction was required to make the apparatus work properly for the CMP slurry or liquid blending application. This led to optimization experiments which discovered settings which overcame the problem, reduced the flow-backpressure interaction, and allowed flow and backpressure to be adequate at the same time. In the preferred embodiment, at least some portion of the liquid is flowing through all parts of the recirculation loop continuously when the pump is operating, and the other portion (the balance) of the liquid flows to the flow controller.

## BRIEF DESCRIPTION OF SEVERAL VIEWS OF THE DRAWINGS

**[0043]** FIG. 1 is one embodiment of an apparatus of this invention.

**[0044]** FIG. 2 is a second embodiment of an apparatus of this invention.

**[0045]** FIG. 3 is a third embodiment of an apparatus of this invention.

5

## DETAILED DESCRIPTION OF THE INVENTION

**[0046]** This invention, apparatus and method, were designed for providing a controlled flow for the purposes of blending a raw CMP slurry with other chemical components to make blended slurry. It is recognized that it may be used for any liquid. It is further recognized that multiply apparatuses can be used together to feed different liquids to a single blending apparatus. It is further recognized that the apparatus and method of this invention may be used to directly provide, for example any tool (not just a blending apparatus) or use that requires a well-controlled flow of a liquid. Therefore, it is understood that any use of term “slurry”, “raw slurry” or “CMP slurry” herein may be replaced with “liquid”, and the use of “liquid” may be replaced with “slurry”, “raw slurry” or “CMP slurry” unless the context requires differently. Further the apparatus of the invention may be described as having blending equipment attached thereto. It is understood that any tool or downstream use could be substituted for the mixing or blending equipment described or shown herein.

**[0047]** The liquid wetted parts of or used in this invention are made of chemical resistant, high purity materials such as polyfluoroalkoxy (PFA) or polytetrafluoroethylene (PTFE), or similar types of materials unless otherwise noted. The device liquid port connection to the tube is made with fittings such as Flare, Primelock, NPTF, NPTM or other fittings, made of chemical resistant, high purity materials such as PFA or PTFE, unless otherwise noted. Some devices also have air ports. The air port fittings and tubes may be made of non-PFA, non-PTFE materials.

**[0048]** The use of the term “flow meter” herein includes flow meters that measure a flow rate measurement and display that measurement via a gauge, dial or electronic display, etc. and flow transmitters which can be used to electronically communicate flow rate measurements to controllers.

**[0049]** The use of the term “electrically connected” includes any form of signal communication, which can be by hard-wires, or radio or electrical waves.

**[0050]** FIG.1 shows an apparatus of this invention that comprises a recirculation loop **100** which comprises the following components: liquid supply container **1**, suction diptube **2**, liquid transfer pump **3**, pump controller **4**, source of gas **5**, filter housing **6**,

junction or tee **7**, variable area flow meter **8** with needle valve **9**, and return diptube **10**. The recirculation loop supplies liquid from the recirculation loop to a flow controller **100** that is in fluid communication with the recirculation loop. If the liquid is a raw slurry it may be combined with another slurry component stream to form a blended slurry.

5 **[0051]** In FIG. 1 the apparatus of this invention comprises at least one liquid transfer pump **3** for removing liquid from a liquid supply container **1**. Liquid is typically supplied in liquid supply containers of 55 gallons or totes of 300 gallons. Typically the liquid supply containers have openings only on the top, thereby typically requiring a diptube **2** which is inserted into the liquid supply container and provides suction when the pump is  
 10 operating. The diptube **2** is typically long enough so that the tip is close to the bottom of the liquid supply container so that most of the liquid in the liquid supply container can be removed. Also required is a pump with suction lift capability, so the pump can lift the liquid out of the container. The pump must also provide flow rate sufficient to supply the flow controller. Operating the pump in the apparatus must produce low pressure  
 15 fluctuation at the flow controller **100** inlet. Pump inlet ports may be Flare, FNPT or flanged. The pump inlet port size may be 1/4", 3/8", 1/2", 3/4" or 1". The pump outlet port may be the same size as the pump inlet port or be a different size. The preferred embodiment pump port size is 1/2" inlet, 1/2" outlet, with Flare fittings. The pump may be a Trebor Purus CP.

20 **[0052]** The pump **3** is defined as a type with suction lift capability, typically bellows pump or diaphragm pump having one or more diaphragms or bellows, in some embodiments dual diaphragms or bellows. The maximum flow of pump **3** may match the maximum flow of the flow controller **100**, or, the pump **3** may supply between from 1 to 3 times the maximum flow of the flow controller **100**, or the pump **3** may supply between  
 25 from 1 to 5 times the maximum flow of the flow controller **100**. The pump **3** may be selected so that when it is pumping it supplies 50 LPM maximum flow, or 25 LPM maximum flow, or 6 LPM maximum flow. The flow controller **100** may be selected to control the flow from 0-20 LPM, or 0-10 LPM, or 0-5 LPM, or 0-2.5 LPM, or 0-1.25 LPM.

**[0053]** The pump **3** of this embodiment may be a low pressure fluctuation pump. The  
 30 low pressure fluctuation is of a kind that is produced by a pump with two independent diaphragm chambers, a first chamber and a second chamber, which operate in five steps. In each step, the pump is discharging a nearly constant flow of liquid. In the first step, the first chamber is under pressure (discharging) while the second chamber is under vacuum (suction). In the second step, the first and second chambers are under  
 35 pressure (discharging, cross-phase). In this step, the term cross-phase refers to the capability of this pump to combine the discharge from two chambers in a balance that

prevents the reciprocating pump change-over pressure drop noted in prior art. In the second step, the first chamber pressure falls while in parallel the second chamber pressure rises. In the third step, the first chamber is under vacuum (suction) while the second chamber is under pressure (discharging). In step 4, the first and second chambers are under pressure (discharging, cross-phase). In step 4, the first chamber pressure is rising while in parallel, the second chamber pressure is falling. Step 5 repeats step 1 to start a new 5-step cycle that repeats over and over. As the cycle progresses, each chamber alternates being under pressure, then under vacuum, with the cross-phase period in between.

10 **[0054]** The pump **3** has maximum pilot pressure 80 psig, and maximum liquid pressure 60 psig. The maximum flow capacity for pump **3** is 6 LPM. Nominal operating parameters of the this pump with cycle rate of 10-20 and 50% overlap produces a flow rate of about 3 LPM. It is possible to operate this pump with 20-30 psig of backpressure, and in fact this improves the pump **3** pressure fluctuation suppression which can be provided by a  
15 back pressure controller which in this embodiment is needle valve 9 and rotometer 8. This pump solves the pressure drop problem found in most diaphragm pumps when the chamber switches from suction to discharge. Instead of a pressure drop during switch-over, this pump employs cross-phase discharge. This causes the pressure to remain stable during the period when prior art pumps experience a pressure drop. There is no  
20 pressure fluctuation suppression device in this pump. Its design is thus robust against reliability concerns related to pulsation dampeners.

**[0055]** The pump **3** is preferably situated as low as possible in the apparatus. It may be mounted on a saddle (not shown) which raises the pump off the floor to minimize vibration transfer to the rest of the apparatus. The pump is operated by gas. This low  
25 pressure fluctuation pump **3** constitutes the first stage of pressure fluctuation suppression.

**[0056]** The apparatus of this invention further comprises a pump controller **4** connected to and controlling the pump. The pump controller supplies gas, to the one or more diaphragms or bellows of the pump, from a source of gas. The pump controller also  
30 supplies negative pressure (vacuum) to the diaphragms or bellows of the pump. The pump controller may supply gas or vacuum to the diaphragms or bellows of the pump separately. In one embodiment, the pump controller may comprise a programmable logic relay, two solenoid valves, two venturi vacuum generators, two variable restrictor nuts restricting gas or vacuum flow to the pump diaphragms or bellows, a precision  
35 regulator, an exhaust muffler, and tubing and fittings to connect the parts of the controller. The programmable logic relay (PLR) is electrically connected to the



solenoids. When operating, the PLR turns the solenoids on and off when instructed by an application program loaded in the PLR memory. The venturi vacuum generators supply negative pressure to the pump gas ports when the solenoids are turned off. The PLR and solenoid valves are electronic and require a source of power. The precision  
5 regulator controls gas backpressure in the pump. The solenoid valves supply gas to the variable restrictor nuts. The variable restrictor nuts each supply one diaphragm of the pump. The precision regulator, venturis, and solenoid valves of the pump controller all require a source of gas **5**. One useful pump controller is available from Trebor.

**[0057]** The apparatus of this invention further comprises an optional filter(s) in one or  
10 more filter housings, shown as a single filter housing **6**. FIG. 1 shows the filter housing on the discharge side of the pump. Alternative embodiments of the invention would alternatively or additionally place one or more filter housings on the suction side of the pump, or next to the inlet of the flow controller, or between the needle valve and the liquid supply container. The filter housing may be any size, for example, 10 to 20 inches  
15 or 10 or 20 inches in vertical length, and be made of polypropylene or PFA material. The housing may be right side up, with the bowl located below the inlet and outlet ports, or inverted, with the bowl above the inlet and outlet ports. The housing may also have the inlet port on the bottom of the bowl instead of on the side of the housing. The preferred embodiment is to locate the filter inlet as close to, meaning within 24 inches or within 12  
20 inches of the pump discharge port, with inverted bowl and side inlet.

**[0058]** The apparatus of this invention further comprises a junction or tee **7** in the recirculation loop. The tee provides a path to recirculate liquid back to the liquid supply container as well as a path to supply the liquid flow controller. The recirculation path is useful to maintain a stable colloidal suspension, if the liquid is CMP slurry, in the  
25 apparatus and in the liquid supply container, to keep the CMP slurry or other liquid homogenized and sediment-free. The different lengths of suction **2** and return **10** insert tubes in the liquid supply container provide a means to collapse concentration or density gradients as recirculation turns the liquid supply container over. The recirculation loop further has a means to adjust backpressure in the recirculation loop such as a needle  
30 valve or pneumatic or electronic control valve or flow controller.

**[0059]** On one side downstream of the tee **7**, the apparatus of this invention, as shown, further comprises a variable area flow meter **8** and needle valve **9** as a means to adjust the backpressure in the recirculation loop. The flow meter **8** provides visual indication of flow by the movement of the float behind the window, which is marked to indicate flow.  
35 Closing the manually operated needle valve **9** causes backpressure upstream of the valve to increase, and causes flow to decrease. In alternative embodiments of the

invention, the flow meter **8** may be an electronic flow meter. In alternative embodiments, valve **9** may be an electronic or pneumatically powered control valve. In alternative embodiments, valve **9** may be a control valve that operates on feedback from a pressure transducer added to the recirculation loop upstream of the control valve.

5 **[0060]** On the other side downstream of the tee **7**, the apparatus of this invention further comprises an optional isolation valve **11** that may be a pneumatic valve **11**. This valve may be used to block the flow to the flow controller, to allow for the maintenance or replacement of the flow controller while the rest of the system remains operational.

**[0061]** The apparatus of this invention further comprises a liquid flow controller **100**.

10 The flow controller **100** comprises a flow meter **12**, a control valve **13** and a control device (a controller) **14**. The flow controller **100** flow meter **12** may operate on an ultrasonic, rotating turbine or wheel, vortex, electromagnetic, coriolis, or differential pressure principle. The preferred flow meter operating principle is differential pressure, which provides the fastest response of any of the operating principles. The flow meter  
15 **12** is electronically connected to the control device **14** and fluid flows from the flow meter **12** to the control valve **13**. The control valve **13** is normally closed. When instructed by the control device **14**, the control valve **13** opens partially or fully, depending on the flow sensed by the flow meter **12**. Flow controller units have different flow ranges. Flow controllers useful in this invention are made by Entegris. Useful controlled regulators **13**  
20 of the flow controller may have an upper and lower diaphragm joined by a shaft having a closure member, the shaft running through the valve orifice. The lower (inlet) diaphragm will move the closure member in response to pressure fluctuations. This controlled regulator **13**, embedded in the Entegris 6510 flow controller, constitutes the second stage pressure fluctuation suppression. Because the controlled regulator **13**, as shown,  
25 is downstream of flow meter **12** in Figure 1, the pressure fluctuation suppression effect cannot be measured by the flow meter **12**. In some flow controllers, the flow meter **12** and control valve **13** are embedded in a single body in the arrangement. It may be beneficial to use flow controllers in which the flow meter is downstream of the control valve or regulator as shown in the embodiments of Figures 2 and 3.

30 **[0062]** Flow controller **200** performance depends on the speed and accuracy of the flow meter **12**, the speed and accuracy of the control algorithm of the control device **14**, the speed and accuracy of the control valve **13**, and the pressure and pressure fluctuation at the inlet to the flow meter **12**. When the pressure fluctuation is low, the blending result is improved. The pressure fluctuation of the pump **3** is one factor that  
35 influences the pressure fluctuation in the apparatus, but not the only factor. Other factors include the orientation of the filter housing, if present, the presence of gas in the

filter housing which may be in the top of the inverted filter housing, the amount of trapped gas in the filter housing, the pressure of the trapped gas, the ratio of trapped gas to liquid in the filter housing, the filter in the filter housing, the size of the filter housing, the compensation for pump pressure fluctuation provided by backpressure control device **9**,  
5 and tube sizes, volume, and orientation. Other factors influencing flow controller accuracy are pressure and flow supplied to the flow meter **9**.

**[0063]** The inventors have devised an apparatus, including a pump **3**, filter housing **6**, tubing, and backpressure control device **9** that provides low pressure fluctuation, adequate flow, and adequate pressure to the inlet of the flow meter of the flow controller  
10 **100**. The apparatus requires only one pump. As has been mentioned previously, there are several vendors that make suitable types of each of these devices. The invention is not constrained to one vendor or device. Furthermore, vendors provide several sizes of each of these devices. For example, a pump of the invention may have 1/2" Flare ports, and supply 3 LPM of flow, or 1" Flare ports and 100 LPM of flow.

**[0064]** When pressure fluctuation in the apparatus is significant, the blending performance is degraded. The flow meter **12** rapidly detects this fluctuation. The control device **14** signals the control valve **13** to adjust in response to the fluctuation. This control valve, flow meter, and control device are fast responding devices, but do not respond instantly. The lag in response is problematic when pressure fluctuation is  
20 greater than +/- 10%, or +/- 5%, or +/- 3%. The pressure fluctuation pulses from a prior art diaphragm pump are high-frequency. When the frequency of the fluctuation is greater than the sum of the lag times of the flow meter **12**, control valve **13** and control device **14**, which is termed "flow controller lag", the cycle of flow meter **12** detecting a change, and control device **14** signaling the control valve **13** to adjust, will occur too  
25 slowly to be effective. To be effective, the flow controller lag must be reduced or the pulse frequency decreased. The invention provides a way to reduce pulse frequency to ensure that the flow controller has sufficient time to respond.

**[0065]** The apparatus of this invention further comprises a liquid check valve **15**. In the embodiment shown in FIG 1, the check valve is connected to a tee that is connected to a  
30 supply line **40** containing a second liquid component to be blended with the first liquid component to make a blended liquid, that may be a blended slurry. The second ingredient may be supplied by a pressurized source. If the pressure of the second ingredient is higher than the pressure of the first ingredient, there would be backflow, rather than mixing. The check valve **15** prevents backflow, thereby ensuring mixing  
35 occurs.

**[0066]** The apparatus of this invention further comprises a tee **23** connected downstream of both check valve **15**, and check valve **22** and a mixing device **16** downstream of the tee **23**. The tee, alone or in combination with optional one or more check valves, and/or optional one or more mixing devices, plus the tubing connecting these optional devices, create a mixing manifold. The mixing manifold described here is a simple one, mixing two ingredients and may just be a junction or tee. Alternatively, additional one and/or more check valve(s), mixer(s) and tee(s) could be added to it. Alternatively, a second manifold, with a one or more tees, one or more check valves, and one or more mixers in any combination, may be used to mix two more ingredients.

Following the second mixing manifold may be a final mixer that combines the products of the first two manifolds into a final product. Two mixing manifolds plus a final mixer is an embodiment of the invention for mixing up to four ingredients. Another embodiment is a single mixing manifold that mixes three ingredients at once. Many different combinations are possible.

**[0067]** Mixing manifolds may be supplied with ingredients to mix via flow controllers. They could also be supplied by volumetric beakers, pressure vessels, or pumps. In other embodiments, mixing manifolds may be constructed to bring ingredients together without the use of a tee. Tee-less manifolds bring ingredients together by forming multiple passages in a single piece of material with multiple fluid ports, whereby the passages come together inside the manifold. The manifold may be a single plastic manifold. These integrated mixing manifolds may have check valves physically attached to the manifold.

**[0068]** Mixing manifolds or mixers may employ several mixing techniques. One common mixing technique is to create turbulence in the flow path via specially-designed inserts in the flow path. These inserts have been designed using computation fluid dynamics and practical tests so that they generate sufficient turbulence to aid the mixing of ingredients. Another mixing method is cyclonic mixing, which swirls two or more ingredients together in a bowl, passing each ingredient through a spiral bushing which imparts a twisting motion to the ingredients, aiding their mixing.

**[0069]** As shown, the apparatus of this invention further comprises a second ingredient reservoir **18**. This reservoir may be pressurized to supply a bulk chemical distribution manifold, for distribution to points of use. The apparatus of the invention described would be one such point of use.

**[0070]** The apparatus of this invention, as shown, further comprises an optional second ingredient flow controller **200**. The optional flow controller **200**, as shown comprises of a

flow meter **19**, a control valve **20** and a control device **21**. The flow meter **19** is connected to the control valve **20**. The flow meter **19** is also electrically connected to the control device **21**. The control valve **20** is connected electrically to the control device **21** also. The operation of flow controller **200** is analogous to the operation of flow controller **100**, which has been described above. Port sizes, flow ranges, and pressure ranges may be the same or different with flow meters **12** and **19**. Control valves **13** and **20** may have the same or different port sizes, maximum flow, internal orifice size, and other characteristics.

**[0071]** Variation in the pressure supplied to the flowmeter **19** inlet must be minimized in order for blending accuracy to be maximized. The pressure variation in pressure-distribution systems is usually much less than +/- 10%, or +/- 5%, or +/- 3%, and preferably any variation that occurs is usually low-frequency, the type of variation the flow controller can easily control.

**[0072]** The apparatus of this invention further comprises a reservoir **17** for the blended product. Commonly, product is stored in a tank or other vessel prior to distribution to points of use or further filtration or other processing. An alternative embodiment of the invention would be a small reservoir, or no reservoir, providing direct distribution of the blended product to a point of use. It is also common to bypass the reservoir **17** and direct blended product to waste drain for a period of time to pack the lines in the blending manifolds and supply apparatus, removing aged product, and so the flow controllers have sufficient time to stabilize. Flow controllers typically stabilize after 3 seconds, meaning a line pack time of at least 3 seconds is optimal. After the line pack time has expired, the apparatus will fill the reservoir **17**, or distribute blended slurry product to a point of use, or dispose of the blended slurry product some other way.

**[0073]** The process of the invention solves the problems mentioned in the background of the invention. These problems are related to physical quantities flow, pressure, and pressure fluctuation under different conditions (filtration, priming, and general operation). The objective is to provide sufficient flow, sufficient pressure, and minimal pressure fluctuation to the inlet of the flow controller's flow meter.

**[0074]** An additional embodiment of this invention is shown in FIG. 2. As shown in FIG 2, chemical vessel **1** contains the liquid which will be delivered to the flow meter **12a**. This liquid may be a high purity semiconductor-grade chemical, a CMP slurry, or any liquid. The suction line **28** connects the chemical vessel to the bellows pump **3a**. The suction line may be preferably ½" outer diameter Entegris Fluoroline XKT tubing made of Daikin AP-231SH resin. Alternative tubing from Saint Gobain or Zeus or other resins

such as Dupont 450HP or 950 are also suitable. Larger diameters may be used to improve suction line performance, such as  $\frac{3}{4}$ " or 1". Other tubes in the system are of the same Entegris Fluoroline XKT tubing unless otherwise noted.

5 [0075] In some alternative embodiments, suction line **28** may contain a strainer, manual isolation valves, or pneumatic air operated valves.

[0076] The pump **3a** is a bellows pump having moderate pressure fluctuation. A One useful pump is available from Saint Gobain Asti. The moderate pressure fluctuation is of a kind produced by a bellows pump with air consumption of 6 SCFM or less, with maximum pump operating pressure 0.5 MPa or less. This produces a pressure  
10 fluctuation with relatively low frequency and amplitude. The pump is preferably situated as low as possible in the apparatus. It may be mounted on a saddle to minimize vibration transfer to the rest of the apparatus. The pump is operated by air or nitrogen, or other inert gas. The inert gas is supplied to the pilot port of the pump **3a** via the air tube **29**. The air tubing is preferably 1/8" outer diameter, or larger. Tubing **29** may be  
15 made out of FEP or other plastic. The air tube **29** supplying the pump may need to be a larger outer diameter if the line is longer than 3 meters. The pump **3a** is supplied by controller **4a** connected by tube **29**. In some alternative embodiments, air tube **29** may contain a 2- or 3-way solenoid-actuated valve to turn air supply to the pump on and off.

[0077] Pump **3a** is preferably operated at a pilot pressure of 0.35 MPa. The maximum  
20 pilot pressure is 0.5 MPa and the minimum is 0.2 MPa.

[0078] Controller **4a** is preferably a Numatics Sentronic D or Sentronic Plus. This controller has an electrical connector for receiving setpoint, power, and external feedback signal, **35**, from the flow meter 34. The controller receives a signal from flow meter **34**. This signal becomes the basis for a cascade control scheme set in the  
25 controller **4a** firmware. Cascade control means there are two loops, a slave and a master, with the master providing input to the slave loop. The master loop operates off the external feedback (flow meter 34). The slave loop operates off the outlet pressure transmitter which is internal to the controller 4a and measures the pressure in line 29. When there is a difference between the flow meter 34 setpoint and the flow meter  
30 feedback signal 35, this causes a change to the internal pressure setpoint within the controller 4a. The aggressiveness of the change depends on how the master firmware is tuned. This in turn causes the internal pressure transmitter to register an error signal in the pressure control loop. The pressure transmitter error results in the controller adjusting pressure supply to the pump **33a**. The aggressiveness of the change depends  
35 on how the slave firmware is tuned. There are many parameters in the firmware which

affect how the controller responds to signals, which can be adjusted by the engineer. The firmware is set so that the pressure range is 0.5 - 0.2 MPa. To summarize, controller **4a** receives a signal from the flow meter and adjusts pressure supply to the pump **33a** to maintain a flow rate setpoint.

5 **[0079]** The pump **33a** is connected via a tube to an optional filter housing **6**. The filter housing is is the same as described in the first embodiment.

**[0080]** The filter housing **6** is connected via a tube to dome loaded pressure regulator **30**. A useful regulator is available from SMC with a flow capacity of 40 LPM. (In other embodiments, the volumetric flow capacity of the regulator may be approximately 20 to 10 50 LPM). This compares with pump **3a** maximum volumetric flow rate 2.5 GPM (9.5 LPM), a ratio of approximately 4:1. In other embodiments, this ratio may be from 2.5:1 to 5.5:1 or from 3:1 to 5:1 or 3.5:1 to 4.5:1. The maximum pressure (pilot and liquid) is 0.5 MPa, with 0.4 MPa (pilot and liquid) being practical nominal operating maximum pressures. The optimum pilot pressure range for maximum pressure fluctuation 15 suppression is 0.15 +/- 0.05 MPa. The lower the pilot pressure, the better the pressure fluctuation (of the liquid) is suppressed. The pilot pressure controls the valve opening %; lower pressure causes the valve to open less. This reduces the flow rate. When the pump **3a** is supplied with 0.35 MPa pilot pressure, and regulator **30** is supplied with 0.1 MPa pilot pressure, the flow rate in the system is about 3 LPM, and pressure fluctuation 20 is so minor that the float of a rotameter is visibly steady. At 0.2 MPa regulator **30** pilot pressure, the rotameter float will bob slightly, indicating a small amount of pressure fluctuation. The larger regulator valve opening at 0.2 MPa causes the flow rate to increase. This regulator constitutes the first stage of pressure fluctuation suppression.

**[0081]** Dome loaded regulator **30** is a pressure reducing regulator. That means 25 supplying regulator **30** with 0.1 MPa pilot pressure causes the outlet liquid pressure to be reduced to less than 0.1 MPa. The liquid supply pressure must be at least 0.2 MPa to obtain 0.1 MPa outlet pressure. Higher inlet pressure (0.35 MPa is the pump nominal operating pilot pressure) results in a greater pressure reduction, and greater effectiveness of pressure fluctuation suppression.

30 **[0082]** The dome loaded regulator **30** is provided with pressure via air tubing **31**. This tube can be 1/4" or 5/32" outer diameter, and made of any plastic material, although FEP is preferred. The tube leads to a direct-operated air regulator, **32**. A common part used is available from SMC. There are many others that are commercially available.

**[0083]** Regulator **30** is connected to flow meter **34**. The tube connecting them is 35 chemical resistant PFA and can be any size large enough to handle the flow rate from

regulator **30**. A ½" tube size is preferred. A suitable flow meter part is from SMC. Flow meter **34** is in electrical communication with controller **44** shown by the dashed line **35**. In some embodiments, the flow meter **34** is a variable area flow meter, such as those available from Futurestar.

5 **[0084]** The fluid next passes through a tee, **7**. The first branch, **10**, is the return tube to chemical vessel, **1**. This provides a path for recirculation of the liquid not consumed by the flow control system 200.

**[0085]** The recirculation loop 300 comprises (optional chemical vessel **1**), suction tube **2** (into the chemical vessel **1**), pump **3a**, regulator **30**, flow meter **34**, and return tube **10**  
10 and one or more backpressure units **24a** and **24b** located on the return tube 10 (into the chemical vessel 1). The regulator is located downstream of the pump and the flow meter is located downstream of the regulator. The regulator may be an electronically controlled regulator or a mechanically controlled regulator. This loop may be referred to as the pump flow control loop, since the flow meter **34**, pump **3a** and controller **4a** combine to  
15 control pump flow.

**[0086]** In some alternative embodiments, return line **10** (which is located downstream of the junction 7) may have one or more of the following: a filter, manual isolation valves, pneumatic air operated valves, manual backpressure control system **24a** having a variable area flow meter **8** and manual back pressure control valve **9**, and/or  
20 backpressure control system **24b** having a pressure transducer 25 electrically connected to a controller **26**, which controls a pneumatic-actuated control valve 27.

**[0087]** Downstream of the junction 7 is the flow control system **100** having fluidly connected dome loaded regulator **13a**, flow meter **12a** and optional isolation valve **11** and also having a controller **14a** in communication with the flow meter via the electrical  
25 connection 30 and controlling the regulator 13, since the object of this portion of the apparatus is to control flow through flow meter **12a**. Regulator **13a** is fluidly connected to tube 36, which is connected to the tee **7** and thereby to the recirculation loop 300, via optional isolation valve **11**. In some embodiments, useful isolation valves may be pneumatic or manual isolation valve **11** fluidly connected between tee **7** and regulator  
30 **13a**.

**[0088]** Tube **28** downstream of the isolation valve 11 feeds the regulator **13a** and flow meter **12a**. The tube size may preferably be ¼" outer diameter. Since the regulator 13a is controlled by the electronic controller 14a (which gets signal inputs from the flow meter 12a and controls a valve (not shown) within the controller 14a that controls the flow of  
35 the gas from gas supply 5 to the regulator 13a via line 39), it may be referred to as a



controlled regulator. (This is in contrast to the regulator 30, that is supplied with air pressure from manual regulator 32 that uses a fixed manual adjustment method.) Further, since the controlled regulator 13a and 14a also has a controlled valve (also referred to as a control valve), and works in response to flow transmitter 12, those three components together may also be referred to as a flow controller.

[0089] The tube 36 is connected to dome loaded pressure regulator 13a. A useful regulator is available from SMC having a flow capacity of 4.5 LPM. The maximum pressure (pilot and liquid) is 0.5 MPa, with 0.4 MPa (pilot and liquid) being practical nominal operating maximum pressures. The optimum pilot pressure range for maximum pressure fluctuation suppression is 0.15 +/- 0.05 MPa. The lower the pilot pressure, the better the pressure fluctuation is suppressed. The pilot pressure controls the valve opening %; lower pressure causes the valve to open less. This reduces the flow rate. When the output from pressure regulator 30 is about 0.2 MPa pressure, and pressure regulator 13a is supplied with 0.1 MPa pilot pressure, the regulator will reduce the liquid pressure to less than 0.1 MPa, while suppressing pressure fluctuation. This regulator 13a constitutes the second stage of pressure fluctuation suppression. In this embodiment, the effect of the pressure fluctuation suppression will be measured by the flow meter 12a, downstream of the pressure regulator 13a.

[0090] The regulator 13a is connected to a controller, 14a, via air tube 37. Air tube 37 will be 1/4" or 5/32" outer diameter and is preferred to be FEP, but can be any plastic. The controller 14a is a Sentronic D or Plus. The controller is operated in the same way as described for 44a, except the controller adjusts gas pressure to regulator 13a. The controller firmware is set to supply a gas pressure range of 0.15 +/- 0.05 MPa to regulator 13a. To summarize, controller 14a receives a signal from the flow meter 12 and adjusts gas pressure supply to regulator 13a to maintain a flow rate setpoint as measured by the flow meter 12a.

[0091] Regulator 13a is connected to flow meter 12a via a tube. Flow meter 12a is connected to controller 14a via electrical connection 39. Flow meter 12a may be a Levitronix Leviflow ultrasonic flow meter with flow range 0-4 LPM. Ultrasonic flow meters can measure flow rates accurately even when liquid pressure is less than 10 psig.

[0092] Controller 14a, regulator 30 and controller 4a are all supplied by regulator 40. Regulator 40 is a larger capacity regulator with maximum flow rate capacity 1500 LPM. A common part is from SMC. There are many similar parts that are commercially available. Regulator 40 is supplied by pressurized gas, typically air or nitrogen, supply 5.

[0093] Following the flow meter **12a**, the fluid flows through a check valve **15**, which prevents backflow, and then to a tool or into another part of the system which may be for blending as described above and as shown in Figure 1. Multiple (more than one) low pressure fluctuation flow control apparatuses each comprising recirculation loops and flow control systems may be employed in the larger system in which multiple liquid components are consumed or blended, etc.. Useful check valves include those from Entegris or Parker.

[0094] A third embodiment of the invention is shown in FIG. 3. The pump **333** of this embodiment is a low pressure fluctuation pump comprising dual diaphragms. This pump operates like the pump of embodiment 1. Suction and discharge strokes alternate with a cross-phase discharge phase occurring between suction and discharge. The pump reduces the pressure drop found in most other diaphragm or bellows pumps, and is free of an integral pulse dampener, which may be unreliable. The pump **3b** has maximum pilot pressure 100 psig, and maximum liquid pressure 80 psig. The maximum flow capacity for pump **3b** is 20 LPM. This is higher pressure and flow capacity than the pump of embodiment 1.

[0095] The dual chambers of pump **3b** are supplied separately via the air tubes **29** and **29a**. The air tubing is preferably 3/8" outer diameter, or larger. Tube **29** and **29a** may be preferably be FEP but any plastic is suitable. The pump **3b** is supplied by controller **4** connected by tube **29** and **29a**. Pump **3b** is preferably a Trebor Evolve 20 "X" model. This pump **3b** constitutes the first stage pressure fluctuation suppression.

[0096] Controller **4** is preferably a Trebor PC15-02. This controller is the same as described in FIG. 1.

[0097] In FIG. 3, the controller **4** receives feedback signals from flow meter **34**. The controller should include PID controller capability, and be programmed to change pump speed when there is a difference between the flow rate measured by the flow meter **26** and the setpoint supplied to the controller **4**. Additionally, the controller should be programmed to change the overlap percent, so that the overlap decreases as the pump cycle rate increases.

[0098] The pump **3b** is connected via a tube to an optional filter housing, **6** located downstream of the pump. The filter housing is the same as described in FIG. 1.

[0099] The optional filter housing **6** is connected via a tube to downstream dome loaded pressure regulator **30a**. A useful regulator available from SMC has a flow capacity of 91 LPM. This compares with pump **3b** maximum flow rate 20 LPM, a ratio of about 4.5:1. In this embodiment, the maximum pressure (pilot and liquid) is 0.5 MPa,

with 0.4 MPa (pilot and liquid) being practical nominal operating maximum pressures. The optimum pilot pressure range for maximum pressure fluctuation suppression is 0.25 +/- 0.05 MPa. As previously described, lower pilot pressure produces lower pressure fluctuation, but also provides lower outlet pressure and lower flow rates. The regulator  
5 can operate at higher outlet pressure while suppressing pressure fluctuations effectively, in combination with a higher pressure supply from pump **3b**. Optimally, the pump **3b** should supply liquid exiting the pump at 60-70 psig to the regulator **30a**. This regulator **30a** constitutes the second stage pressure fluctuation suppression.

[00100] The dome loaded regulator **30a** is provided with gas pressure via tubing **31**.

10 This tube can be ¼" or 5/32" outer diameter, and made of any plastic material, although FEP is preferred. The tube leads to a direct-operated air regulator, **32**, available from SMC, for example.

[00101] Regulator **30a** is connected to flow meter **34**. The tube **33** connecting them is chemical resistant material and can be any size large enough to handle the flow rate  
15 from regulator **30a**. A ½" tube size is preferred. A suitable flow meter part is a 1.8-20 LPM flow rate vortex flow meter made by SMC. Flow meter **34** is connected to controller **4** via electrical connector **35**. In some embodiments, the flow meter **34** is a variable area flow meter, such as from Futurestar.

[00102] The fluid next passes through a tee, **7**. The first branch, **10**, is the return tube to  
20 chemical vessel, **1**. This provides a path for recirculation of the liquid not consumed by the flow control system.

[00103] The recirculation loop 300 has optional chemical vessel **1**, suction tube **2** that is placed into a chemical vessel **1** when it is present, pump **3b**, regulator **30a** and flow meter **34** upstream of the tee **7**, and attached to the tee (and downstream of it) is return  
25 tube **10** and optionally backpressure unit **24a** or **24b** in the return tube **10** back to the chemical vessel **1**. The recirculation loop 300 may also be referred to as the pump flow control loop 300, since the flow meter **34**, pump **3b** and controller **5** combine to control the flow of liquid from the pump. As shown the recirculation loop also has a filter **6**. In alternative embodiments, additional components may be included in the recirculation  
30 loop.

[00104] For example, in some alternative embodiments, return line **10** may contain one or more of the following: a filter, manual isolation valves, pneumatic air operated valves, manual backpressure system **24a** consisting of a variable area flow meter **8** and manual back pressure control valve **9**, or backpressure control system **24b** consisting of a

pressure transducer 25 connected electrically to a controller 26, which controls a pneumatic-actuated control valve 27.

[00105] The combined dome loaded regulator **13b**, flow meter **12b** and controller **14b** is termed the flow control system **100**, since the object of this loop is to control flow through flow meter **12b**. Regulator **13b** is connected to tube 36, which is connected to the tee **7**, via valve **11**.

[00106] Additionally, in some alternative embodiments, there may be an optional pneumatic isolation valve **11** between tee **7** and regulator **13b** or a manual isolation valve between tee **7** and regulator **13b**, or both.

[00107] Tube **36** provides fluid to the regulator **13b** and flow meter **12b**. The tube size may preferably be 3/8" outer diameter. Tube **36** is connected to dome loaded pressure regulator **13b**. A preferred regulator is from SMC with a flow capacity of 15 LPM. The maximum pressure (pilot and liquid) is 0.5 MPa, with 0.4 MPa (pilot and liquid) being practical nominal operating maximum pressures. The optimum pilot pressure range for maximum pressure fluctuation suppression is 0.15 +/- 0.05 MPa. Regulator **13b** will obtain higher flow rates operating at 0.1-0.2 MPa pilot pressure than regulator **13b** of the second embodiment shown in FIG 2, while operating in an effective pilot pressure range for pressure fluctuation suppression. This regulator **13b** constitutes the third stage of pressure fluctuation suppression. In this embodiment, the effect of the pressure fluctuation suppression will be measured by the flow meter **12b**, downstream of the pressure regulator **13b**.

[00108] The regulator is connected to controller, **14b**, via air tube 37. Air tube **37** will be 1/4" or 5/32" outer diameter and is preferred to be FEP, but can be any plastic. The controller **14b** may be a Sentronic D or Plus. The controller is operated in the same way as described for **4a** (FIG.2), except the controller adjusts the gas pressure to regulator **13b**. The controller firmware may be set to supply a pressure range of 0.15 +/- 0.05 MPa to regulator **13b**. To summarize, controller **14b** receives a signal from the flow meter **12b** and adjusts pressure supply to regulator **13b** to maintain a flow rate setpoint.

[00109] Regulator **13b** is connected to flow meter **12b** via the tube shown. Flow meter **12b** is connected to controller **14b** via electrical connection **38**. Flow meter **12b** may be a Levitronix Leviflow ultrasonic flow meter with 0-20 LPM flow range. Ultrasonic flow meters can measure flow rates accurately even when liquid pressure is less than 10 psig.

[00110] Controller **14b**, regulator **30a** and controller **4** are all supplied by regulator **40**. Regulator **40** may be a larger capacity regulator with maximum flow rate capacity 1500 LPM, for example from SMC. Regulator **40** is supplied by air or nitrogen from a supply **5**.

5 [00111] Following the flow meter **112**, the fluid flows through a check valve **15**, which prevents backflow, and then into another part of the system for mixing or other use. The metered amount of liquid downstream of the check valve can be directed into a mixing portion of the apparatus, as shown in Figure 1 to form a blended liquid. An Entegris or Parker check valve may be used. Multiple pump loops **100** and flow controller units **100** may be employed in the larger system for multiple liquid streams.

10 [00112] In use, the operator typically must attach a liquid supply container containing liquid and insert diptube **2**. The pump starts operating, using suction to remove liquid from the container. The liquid recirculates from the container, through the pump, optional filter **6**, in some embodiments regulator **30** or **30a**, and in some embodiments backpressure units **24a** and **24b**, returning to the vessel.

15 [00113] When there is a need downstream and flow control of the liquid is desired, optional valve **11** opens and controlled regulator **13**, **13a** or **13b** (depending on embodiment) opens to start the flow to the flow controller system. The valve in the regulator will adjust the proportion it is open by the controller **14**, **14a** or **14b** (depending on embodiment) adjusting pilot pressure based on feedback from the flow meter **12**, **12a**  
20 or **12b** (depending on embodiment). Regulator **30** and **30a** reduce liquid pressure fluctuation. Pilot pressure is set in the controller **14a** or **14b** to be in the range disclosed by the invention to provide optimum pulsation dampening and flow control. Thus regulator **13**, **13a** and **13b** provide a second or third stage pressure fluctuation suppression and flow control at the same time.

25 [00114] At the same time as **13**, **13a** or **13b** opens, drawing off liquid from the recirculation loop **300**, the flow meter **34** detects the flow rate change (which is reduced compared to setpoint flow rate) and signals the pump **3**, **3a**, or **3b** (depending on embodiment) to adjust speed. The pump may adjust other variables depending upon signals, if any, from the controller.

30 [00115] This invention provides apparatuses and methods to supply a steady volume of liquid with low pressure fluctuation that can be used to form a liquid blend or to supply other equipment or tools. This invention has been described with reference to particular embodiments. It is understood and anticipated that modifications and substitutions can be made to the described embodiments, and that therefore, the invention is not limited to  
35 only the embodiments described.

## CLAIMS

1. A low pressure fluctuation control apparatus comprising:
  - recirculation loop for recirculating a liquid comprising in fluid communication, a dip tube, a pump, a regulator, a flow meter, and a junction in said recirculation loop;
  - 5 flow control system in fluid communication with said recirculation loop via and downstream of said junction,
  - wherein said recirculation loop draws said liquid from a supply container via a dip tube and returns at least a portion of said liquid to the supply container via a return tube downstream of said junction in said recirculation loop,
  - 10 wherein said pump is a diaphragm or bellows type pump.
2. The apparatus of claim 1 further wherein said flow control system comprises a flow controller.
3. The apparatus of claim 2 further wherein said flow controller comprises a flow meter and a controlled regulator in fluid communication.
- 15 4. The apparatus of any of the preceding claims wherein said at least one flow meter is a flow transmitter.
5. The apparatus of any of the preceding claims wherein said flow meters are flow transmitters.
6. The apparatus of any of the preceding claims wherein said flow meter in said flow control system is a flow transmitter.
- 20 7. The apparatus of any of the preceding claims wherein said regulator in said recirculation loop is controlled by a direct-operated air regulator.
8. The apparatus of any of the preceding claims wherein said flow control system further comprises an isolation valve.
- 25 9. The apparatus of any of the preceding claims wherein said flow transmitter in said recirculation loop is electrically connected to a controller that receives a signal from said flow transmitter and adjusts the pilot pressure to said pump.
10. The apparatus of any of the preceding claims wherein said flow control system further comprises a check valve downstream of said flow controller.
- 30 11. The apparatus of any of the preceding claims wherein said recirculation loop further comprises tubes connected to said dip tube, said pump, said liquid flow regulator,

said flow meter, and said junction in said recirculation loop to provide said fluid communication therebetween.

12. The apparatus of any of the preceding claims wherein said flow control system further comprises tubes connecting said flow controller to said junction to provide said fluid communication.

13. The apparatus of any of the preceding claims wherein said controller in said flow control system receives a signal from said flow transmitter in said flow control system and adjusts said gas pressure to said regulator in response to said signal.

14. The apparatus of any of the preceding claims wherein said recirculation loop further further comprises a back pressure controller located in said return tube.

15. The apparatus of claim 14 wherein said back pressure controller comprises a valve and a flow meter.

16. The apparatus of claim 14 wherein said back pressure controller comprises a needle valve and a rotometer.

17. The apparatus of claim 14 wherein said back pressure controller comprises a pressure transducer, a controller and a pneumatic actuated valve.

18. The apparatus of any of the preceding claims wherein said recirculation loop further comprises a filter in said recirculation loop.

19. The apparatus of any of the preceding claims wherein said one or more regulators comprises two diaphragms.

20. The apparatus of any of the preceding claims wherein said regulators comprise two diaphragms.

21. The apparatus of any of the preceding claims wherein said flow meter in said recirculation loop is downstream of said regulator in said recirculation loop and provides backpressure to said regulator.

22. The apparatus of any of the preceding claims wherein said pump is a cross-phase pump.

23. The apparatus of any of the preceding claims wherein the regulator in the recirculation loop is sized such that the ratio of a maximum volumetric flow rate of the regulator to a maximum volumetric flow rate pump is between 2.5:1 to 5.5:1.

24. The apparatus of any of the preceding claims wherein the flow meter of the flow controller in the flow control system is downstream of the control valve of the flow controller in the flow control system.

- 5 25. An apparatus or process of blending liquid, comprising:  
recirculation loop for recirculating liquid;  
liquid material supply line in fluid communication with the recirculation loop, said  
liquid material supply line having a first flow controller; the first flow controller being  
closed-loop control type;  
10 second flow controller for a liquid component to be mixed with the liquid to make  
a liquid blend; the second flow controller being closed-loop control type;  
junction or manifold where the liquid and the one or more other liquid  
components form a blended liquid;

wherein said recirculation loop comprises a back pressure controller, pump  
15 having suction lift capacity, wherein the pump provides means for adjusting its speed  
and means for adjusting one or more or all of the following: chamber overlap, gas  
backpressure, venturi pressure and gas and vacuum flow to the diaphragms or bellows;  
where the process of operating the apparatus comprises directing 20% or less of  
the liquid in the recirculation loop to the liquid material supply line.

20

26. The apparatus or process of claim 25, where the process of operating the apparatus  
comprises having a gas backpressure in the pump that is equal to or greater than the  
liquid pressure in the recirculation loop when the liquid supply pressure is measured in  
the recirculation loop between the pump and the junction with the liquid material line.

25

27. The apparatus or process of any of the preceding claims, where the process of  
operating the apparatus comprises adjusting the gas backpressure and the venturi  
pressure in the pump to be equal +/- 10%.

30

28. An apparatus or process of blending liquid, comprising:  
recirculation loop for recirculating a liquid;  
a liquid material supply line in fluid communication with the recirculation loop,  
said liquid material supply line having a first flow controller; the first flow controller being  
closed-loop control type;

35

second flow controller for a liquid component to be mixed with the liquid to make  
a liquid blend; the second flow controller being closed-loop control type;



mixing junction or manifold where the liquid and the one or more other liquid components form a blended liquid;

wherein said recirculation loop comprises a back pressure controller, pump having suction lift capacity, wherein the pump provides means for adjusting its speed and means for adjusting one or more or all of the following: chamber overlap, gas backpressure, venturi pressure and gas and vacuum flow to the diaphragms or bellows;

where the process of operating the apparatus comprises having a gas backpressure in the pump that is equal to or greater than the liquid pressure in the recirculation loop when the liquid supply pressure is measured in the recirculation loop between the pump and the junction with the liquid material line.

29. An apparatus and process of blending liquid, comprising:

recirculation loop for recirculating a liquid;

a liquid material supply line in fluid communication with the recirculation loop,

said liquid material supply line having a first flow controller; the first flow controller being closed-loop control type;

second flow controller for a liquid component to be mixed with the liquid to make a liquid blend; the second flow controller being closed-loop control type;

junction or manifold where the liquid and the one or more other liquid components form a blended liquid;

wherein said recirculation loop comprises a back pressure controller, pump having suction lift capacity, wherein the pump provides means for adjusting its speed and means for adjusting one or more or all of the following: chamber overlap, gas backpressure, venturi pressure and gas and vacuum flow to the diaphragms or bellows;

wherein the process of operating the apparatus, adjusting the gas backpressure and the venturi pressure in the pump to be equal +/- 10%.

30. The apparatus or process of any of the preceding claims wherein the backpressure controller (or means to adjust the backpressure) in the recirculation loop is manually, electronically or pneumatically adjustable.

31. The apparatus or process of any of the preceding claims wherein said first flow controller for the liquid is set at 1-20 or 2-8 or 1-3 LPM.

32. A method of operating any of the above apparatuses of any of the preceding claims comprising the steps of:

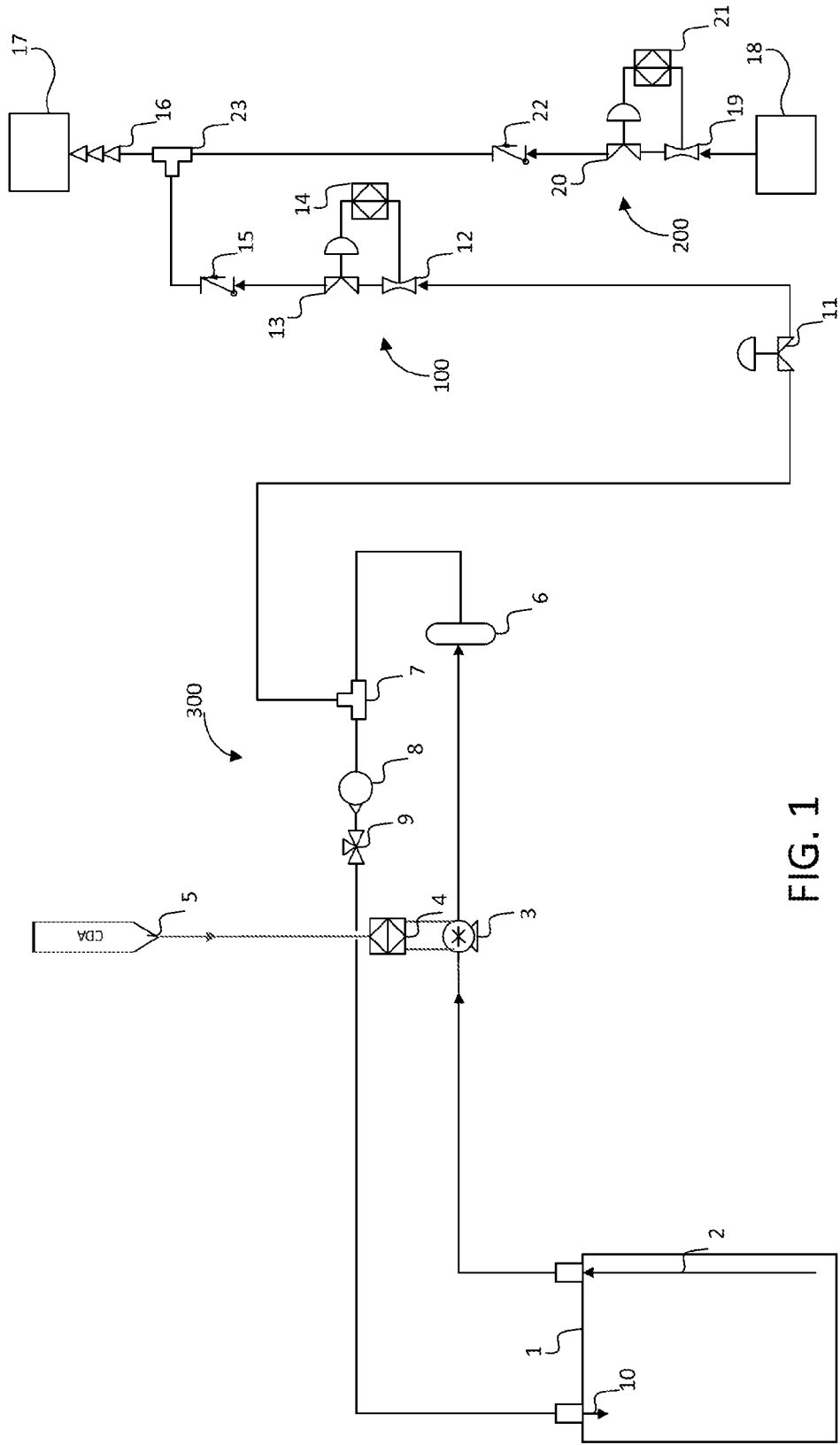
pumping a liquid out of a liquid supply container into a recirculation loop via a pump at a pressure to provide a liquid having a pressure;

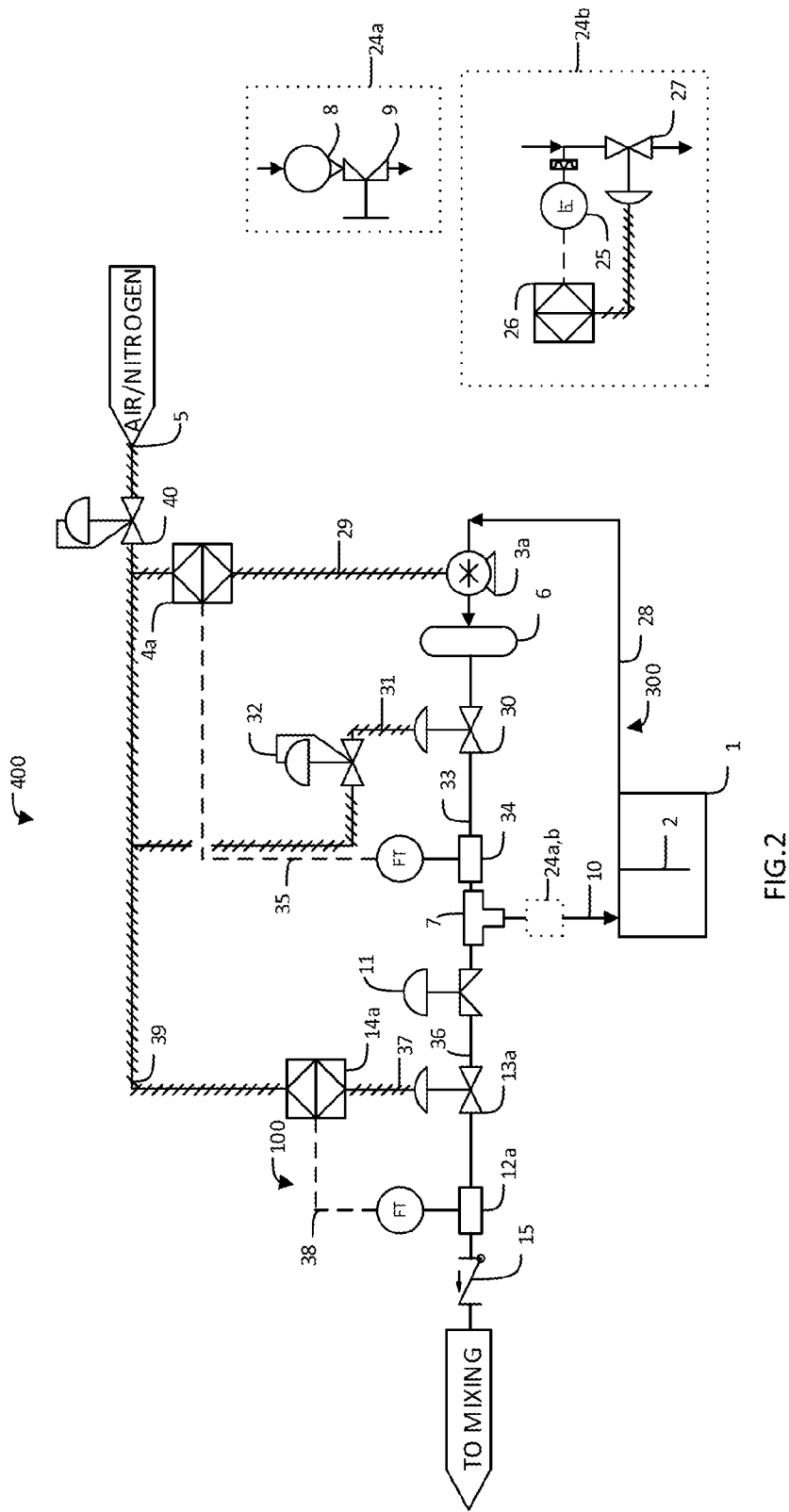
recirculating at least a portion of the liquid back to said liquid supply container in a return portion of the recirculation loop after passing said liquid through a back pressure controller located in said return portion of the recirculation loop; and

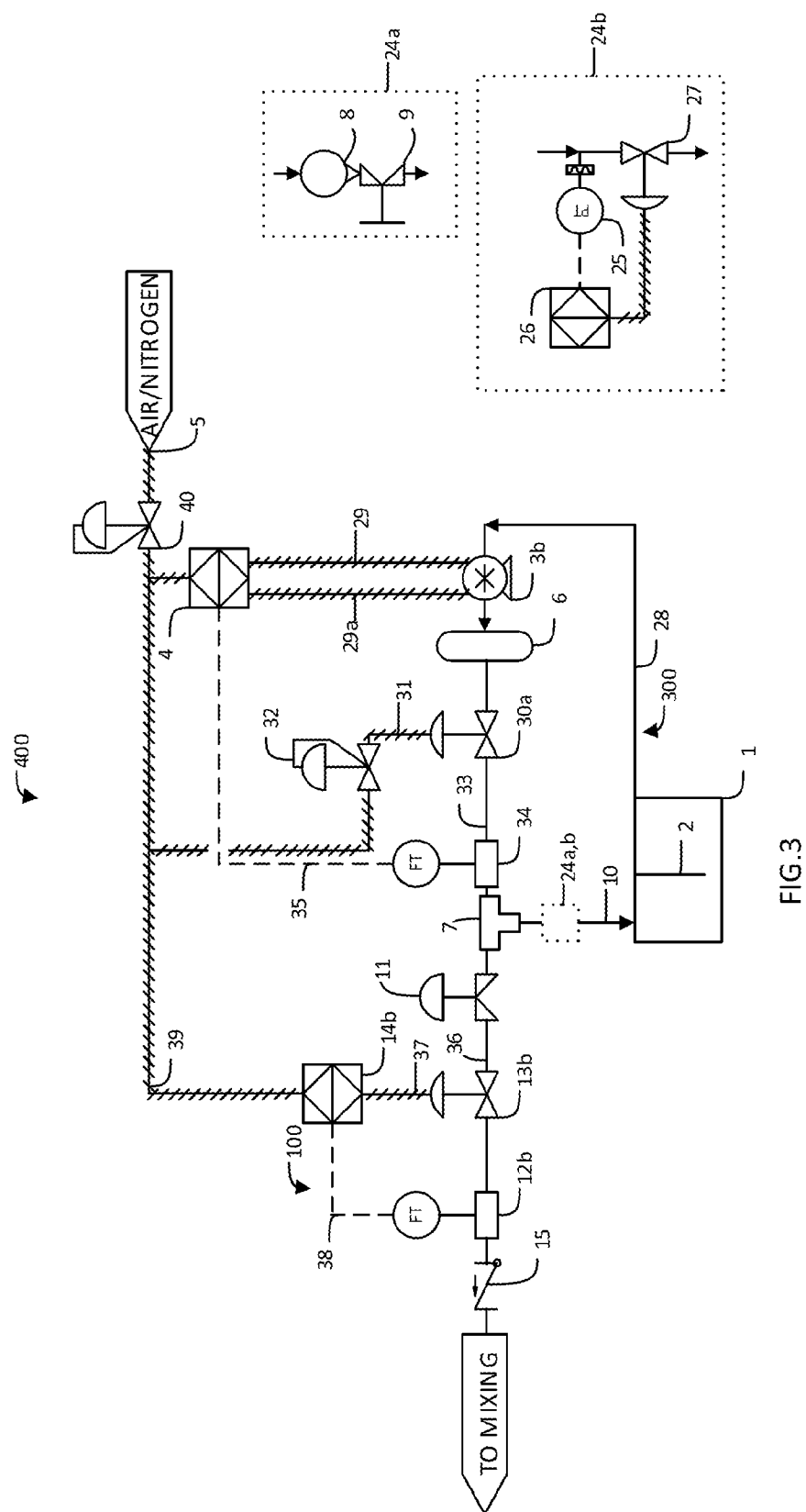
passing the balance of the liquid from the recirculation loop through a flow controller, wherein the flow controller provides a controlled volume of liquid downstream of the flow controller.

33. The method of claim 32 comprising the additional step of:  
flowing the liquid through a regulator in the recirculation loop.

34. The method of claim 31 or 32 comprising the additional step of:  
recirculating at least a portion of the liquid back to said liquid supply container continuously while said pump is pumping.







**A. CLASSIFICATION OF SUBJECT MATTER****G01F 1/34(2006.01)i, G01F 1/20(2006.01)i**

According to International Patent Classification (IPC) or to both national classification and IPC

**B. FIELDS SEARCHED**Minimum documentation searched (classification system followed by classification symbols)  
G01F 1/34; G05B 21/00; B24B 57/02; F04B 49/00; B01F 15/04; B01F 15/02; G01F 1/20Documentation searched other than minimum documentation to the extent that such documents are included in the fields searched  
Korean utility models and applications for utility models  
Japanese utility models and applications for utility modelsElectronic data base consulted during the international search (name of data base and, where practicable, search terms used)  
eKOMPASS(KIPO internal) & Keywords:recirculation loop, flow control system, pump, supply container, flow meter and junction**C. DOCUMENTS CONSIDERED TO BE RELEVANT**

Category*	Citation of document, with indication, where appropriate, of the relevant passages	Relevant to claim No.
X	US 2014-0261824 A1 (AIR PRODUCTS AND CHEMICALS, INC.) 18 September 2014 See paragraphs [0011], [0033], [0090]-[0108], [0200]-[0217] and figures 1A-1C, 7-8, 19.	1-4, 25-26, 28-29
A	US 2002-0034122 A1 (LEMKE, TRAVIS A.) 21 March 2002 See paragraphs [0028]-[0034], [0086]-[0094] and figures 1, 9.	1-4, 25-26, 28-29
A	WO 03-071369 A1 (LAM RESEARCH CORPORATION) 28 August 2003 See paragraphs [0035]-[0048], [0056]-[0059] and figures 2A-2B, 3, 6.	1-4, 25-26, 28-29
A	US 2004-0071555 A1 (CHEN et al.) 15 April 2004 See paragraphs [0029]-[0033] and figures 2-3.	1-4, 25-26, 28-29
A	US 2002-0085447 A1 (SNYDER et al.) 04 July 2002 See paragraphs [0024]-[0034] and figure 1.	1-4, 25-26, 28-29



Further documents are listed in the continuation of Box C.



See patent family annex.

\* Special categories of cited documents:

"A" document defining the general state of the art which is not considered to be of particular relevance

"E" earlier application or patent but published on or after the international filing date

"L" document which may throw doubts on priority claim(s) or which is cited to establish the publication date of another citation or other special reason (as specified)

"O" document referring to an oral disclosure, use, exhibition or other means

"P" document published prior to the international filing date but later than the priority date claimed

"T" later document published after the international filing date or priority date and not in conflict with the application but cited to understand the principle or theory underlying the invention

"X" document of particular relevance; the claimed invention cannot be considered novel or cannot be considered to involve an inventive step when the document is taken alone

"Y" document of particular relevance; the claimed invention cannot be considered to involve an inventive step when the document is combined with one or more other such documents, such combination being obvious to a person skilled in the art

"&amp;" document member of the same patent family

Date of the actual completion of the international search

26 January 2016 (26.01.2016)

Date of mailing of the international search report

**27 January 2016 (27.01.2016)**

Name and mailing address of the ISA/KR

International Application Division

Korean Intellectual Property Office

189 Cheongsa-ro, Seo-gu, Daejeon, 35208, Republic of Korea

Facsimile No. +82-42-472-7140

Authorized officer

LEE, Hun Gil

Telephone No. +82-42-481-8525



**INTERNATIONAL SEARCH REPORT**International application No.  
**PCT/US2015/054698****Box No. II Observations where certain claims were found unsearchable (Continuation of item 2 of first sheet)**

This international search report has not been established in respect of certain claims under Article 17(2)(a) for the following reasons:

1. ☐ Claims Nos.:  
because they relate to subject matter not required to be searched by this Authority, namely:
2. ☒ Claims Nos.: 15-17,33  
because they relate to parts of the international application that do not comply with the prescribed requirements to such an extent that no meaningful international search can be carried out, specifically:  
Claims 15-17 and 33 are not clear under PCT Article 6 because they refer to claim 14 or 32, which does not comply with PCT Rule 6.4(a)
3. ☒ Claims Nos.: 5-14,18-24,27,30-32,34  
because they are dependent claims and are not drafted in accordance with the second and third sentences of Rule 6.4(a).

**Box No. III Observations where unity of invention is lacking (Continuation of item 3 of first sheet)**

This International Searching Authority found multiple inventions in this international application, as follows:

1. ☐ As all required additional search fees were timely paid by the applicant, this international search report covers all searchable claims.
2. ☐ As all searchable claims could be searched without effort justifying an additional fees, this Authority did not invite payment of any additional fees.
3. ☐ As only some of the required additional search fees were timely paid by the applicant, this international search report covers only those claims for which fees were paid, specifically claims Nos.:
4. ☐ No required additional search fees were timely paid by the applicant. Consequently, this international search report is restricted to the invention first mentioned in the claims; it is covered by claims Nos.:

**Remark on Protest**

- ☐ The additional search fees were accompanied by the applicant's protest and, where applicable, the payment of a protest fee.
- ☐ The additional search fees were accompanied by the applicant's protest but the applicable protest fee was not paid within the time limit specified in the invitation.
- ☐ No protest accompanied the payment of additional search fees.

**INTERNATIONAL SEARCH REPORT**

Information on patent family members

International application No.

**PCT/US2015/054698**

Patent document cited in search report	Publication date	Patent family member(s)	Publication date
US 2014-0261824 A1	18/09/2014	None	
US 2002-0034122 A1	21/03/2002	EP 1075675 A1 JP 2002-513178 A KR 10-0548750 B1 TW 249571 B US 6796703 B2 WO 99-56189 A1	14/02/2001 08/05/2002 06/02/2006 21/02/2006 28/09/2004 04/11/1999
WO 03-071369 A1	28/08/2003	AU 2002-359867 A1 CN 1620639 A EP 1474729 A1 JP 2005-518660 A JP 4646517 B2 KR 10-2004-0085187 A US 2003-0158630 A1 US 2004-0199293 A1 US 6732017 B2 US 7054719 B2	09/09/2003 25/05/2005 10/11/2004 23/06/2005 09/03/2011 07/10/2004 21/08/2003 07/10/2004 04/05/2004 30/05/2006
US 2004-0071555 A1	15/04/2004	CN 1487576 A SG 118207 A1 TW 200406025 A TW 578229 B US 6860723 B2	07/04/2004 27/01/2006 16/04/2004 01/03/2004 01/03/2005
US 2002-0085447 A1	04/07/2002	CN 1482943 A CN 1482943 C DE 60128584 T2 EP 1347824 A2 EP 1347824 B1 JP 2004-516931 A KR 10-2004-0012703 A TW 523824 A US 6554467 B2 WO 02-053273 A2	17/03/2004 01/02/2006 17/01/2008 01/10/2003 23/05/2007 10/06/2004 11/02/2004 11/03/2003 29/04/2003 11/07/2002